

### **PATENT APPLICATION**

#### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Masaharu KAWAKUBO et al.

Group Art Unit: 2851

Application No.: 10/581,060

Docket No.: 127873

Filed: May 30, 2006

For:

EXPOSURE METHOD AND DEVICE MANUFACTURING METHOD,

EXPOSURE APPARATUS, AND PROGRAM

## SECOND REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

A Request for Correction of PALM Records was filed on February 16, 2007. A copy of the Request, a marked-up copy of the Official Filing Receipt and a date stamped receipt is attached hereto.

It is respectfully requested that the Corrected Filing Receipt be immediately forwarded to the attorneys of record at the address set forth below.

Respectfully submitted,

Mario A. Costantino Registration No. 33,565

Randi B. Isaacs

Registration No. 56,046

MAC:RBI/ejw

Date: July 13, 2007

OLIFF & BERRIDGE, PLC P.O. Box 19928 Alexandria, Virginia 22320 Telephone: (703) 836-6400 DEPOSIT ACCOUNT USE
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Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

Mario A. Costantino Registration No. 33,565

Stephen P. Catlin Registration No. 36,101

MAC:SPC/ejw

Date: February 16, 2007

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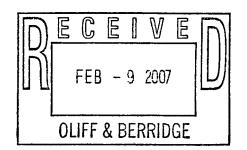
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UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

FILING OR 371 APPL NO. ART UNIT FIL FEE REC'D ATTY.DOCKET NO **DRAWINGS** TOT CLMS IND CLMS (c) DATE 127873 10/581,060 05/30/2006 2851 2230 13 32 6

25944 OLIFF & BERRIDGE, PLC P.O. BOX 19928 ALEXANDRIA, VA 22320





Date Mailed: 02/07/2007

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

Masaharu Kawakubo, Saitama-ken, JAPAN: Yuho Kanaya, Saitama-ken, JAPAN; Chiaki Nakagawa, Saitama-ken, JAPAN; Takahisa Kikuchi, Saitama-ken, JAPAN; Masahiko Akizuki, Saitama-ken, JAPAN;

Power of Attorney: The patent practitioners associated with Customer Number 25944.

#### Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/17447 11/25/2004

Foreign Applications

JP 2003-400210

11/28/03

If Required, Foreign Filing License Granted: 02/06/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/581.060** 

Projected Publication Date: 05/17/2007

Non-Publication Request: No

Early Publication Request: No

Title

Exposure method and device manufacturing method, exposure apparatus, and program

**Preliminary Class** 

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Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process simplifies the filing of patent applications on the same invention in member countries, but does not result in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

Almost every country has its own patent law, and a person desiring a patent in a particular country must make an application for patent in that country in accordance with its particular laws. Since the laws of many countries differ in various respects from the patent law of the United States, applicants are advised to seek guidance from specific foreign countries to ensure that patent rights are not lost prematurely.

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Title 37, Code of Federal Regulations, 5.11 & 5.15

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#### **NOT GRANTED**

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## The following papers have been filed:

Request for Correction of PALM; marked-up copy of OFR



Masaharu KAWAKUBO; Yuho KANAYA; Chiaki NAKAGAWA; Takahisa KIKUCHI; Masahiko AKIZUKI
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Exposure Method and Device Manufacturing Method, Exposure Apparatus, and Program
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